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In the United States Patent and Trademark Office

Serial Number: 09/782,489

Appn. Filed: 02/12/2001

Applicant: Gene E. Lightner

Appn. Title "HYDROGEN DEVOID OF CARBON MONOXIDE FROM A REFORMER"

Examiner/GAU: _____

Mailed: April 9 2001
At: Federal Way, WA.

Information Disclosure Statement

Assistant Commissioner for Patents
Washington, District of Columbia 20231

Sir:

Attached is a completed Form PTO-1449 and copies of the pertinent parts of the references cited thereon. Following are comments on any non English-Language pursuant to Rule 98:

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Very respectfully.

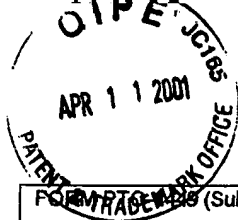
Applicant: Gene E. Lightner

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Enc: PTO-1449 & References

C/O: _____

Telephone: _____

Sheet 1 of 1

FORM 10-6 (Substitute) LIST OF PRIOR ART CITED BY APPLICANT <i>(Use several sheets if necessary)</i>	ATTY. DOCKET NO.	SERIAL NO.09/782,489
	APPLICANT Gene E. Lightner	
	FILING DATE 02/12/2001	GROUP

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE
	AA	5,989,503	11-23-1999	Wiesheu,et al.	422	198	12-15-1997
	AB	5,997,594	12-7-1999	Edlund .et al.	48	76	10-15-1997
	AC	5,639,431	6-17-1997	Shiraski .et a.l	422	212	3-16-1994
	AD	5,938,800	8-24-1999	Verril,et al.	48	127.9	11-13-1997
	AE	5,942,346	18-24-1999	Ahmed,et al.	429	20	7-6-1998
	AF	4,789,540	12-6-1988	Jenkins.	423	648.1	9-4-1986
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS

	AL						
	AM						
	AN						
	AO						
	AP						

OTHER PRIOR ART *(Including Author, Title, Date, Pertinent Pages, Etc.)*

	AR	Merck Index		Anonymous	Pages 208-209		
		Eighth Edition	1968				
	AS	Chemical Process Industries		R. N. Shreve	Pages 126-128	Pages 131-132	Page 136
		Second Edition	1956				
	AT	Argone/ Inemet	2000	Anonymous	Pages 1-2		

EXAMINER

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.